Monday June 5 th	
19h00	
-	Welcome Reception
21h00	

	Tuesday June	6 ^{ui}
08:00	Opening Ce	
08:30	PLENARY SESSION 1	
08:30		331014 1
10:00	Tu-PS1.1 08:30-09:15: M. Kushimoto, CW operation of UVC lasers Tu-PS1.2 09:15-10:00: J. Kim, 2D materials for UV application	
10:00	Coffee b	reak
10:30	A1 – Oxides	B1 UV Phot/UV Char
	Tu-A1.1 10:30-10:55: E. Chikoidze, Ultra Wide Band Gap Gallia and Zinc Gallate electronic properties	Tu-B1.1 10:30-10:55: B. Gil, The Optical Properties of Various Polytypes of sp2-bonded Boron Nitride
	Tu-A1.2 10:55-11:20: T. Onuma, Far UV optical properties of MgO homoepitaxial and Zn doped MgO films prepared by mist chemical	Tu-B1.2 10:55-11:20: Y. Auad, Cathodoluminescence excitation spectroscopy: revealing the excitation pathways in the
10:30	vapor deposition method Tu-A1.3 11:20-11:45: G. Fanchini, Defect-Related Optoelectronic and	nanometer scale Tu-B1.3 11:20-11:45: R. Butte, Polaritonic effects in III-nitride planar
- 12:30	Magnetic Properties of Nanostructured Nickel Oxides as Charge	waveguides and microring resonators
	Transport Layers in Organic Photovoltaics Tu-A1.4 11:45-12:00 : Z. Liu, Ultrathin and Freestanding Ga ₂ O ₃ Membrane	Tu-B1.4 11:45-12:00 : B. Szafranski, Time-resolved cathodoluminescence spectroscopy of oxygen related defects in AIN layers
	Developed by Thermal Mismatch Engineering for Vertical Electronics Tu-A1.5 12:00-12:15: Y. Zhang, Beta-Gallium Oxide nanowire-based electronic	Tu-B1.5 12:00-12:15: K. Korona , Time-Resolved UV Photoluminescence of Color Centers in MOCVD-Grown Boron Nitride
	devices and its low frequency noise analysis Tu-A1.6 12:15-12:30: D. Rogers, High Gain UVC (AI)Ga ₂ O ₃ Photodetectors	Tu-B1.6 12:15-12:30: P. Gonzalez-Izquierdo, Kelvin Probe Force Microscopy under variable illumination: a novel technique to
42.20	with Tunable Spectral Response and Extreme Solar Blindness	unveil charge carrier dynamics in (Al/In/Ga)N
12:30	Lunch / Poste	er session
13:30	A2 2D/Nano	B2 UV emitters
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	Tu-A2.1 13:30-13:55: J. K Kim, Growth of hexagonal boron nitride by MOCVD	Tu-B2.1 13:30-13:55: M. Iwaya, Toward enhancement of light output power of AlGaN-based UV-B laser diodes
13:30	for DUV applications	Tu-B2.2 13:55-14:10: E. Torres-Vasquez, Resonant-cavity UVB LEDs with tunnel-junctions and all-dielectric DBRs
-	Tu-A2.2 13:55-14:10: A. Rousseau, Optical Characterization Of Exfoliated Monolayer Boron Nitride By Means Of Hyperspectral Microscopy In	Tu-B2.3 14:10-14:25: R. Dupuis, Crack suppression of high Al-mole- fraction AlGaN layers on patterned GaN substrates for ultraviolet
15:00	Tu-A2.3 14:10-14:25: V. Ottapilakkal, MOVPE Growth of Thin hexagonal Boron	light emitting diodes and laser diodes
	Nitride on Patterned Epigraphene Tu-A2.4 14:25-14:40: J. Rogoza, Fabrication of hexagonal boron nitride	Tu-B2.4 14:25-14:40 : J. Rass , UV micro-LEDs and micro-LED arrays for high efficiency and new applications
	membranes on germanium for Raman signal enhancement	Tu-B2.5 14:40-14:55: E. Akar, GaN Nanowire Ensembles Ultraviolet Photodetectors based on Photoconductors and Schottky
15:00		Photodiode
15:30	Coffee b	reak
15.50	A3 AIGaN/AIN	B3 2D/Nano
	Tu-A3.1 15:30-15:55: S. Hagedorn, Fabrication of high-quality AIN and AIGaN	Tu-B3.1 15:30-15:55: D. Cai, 2.5-inch hexagonal boron nitride for van der
	templates	Waals heteroepitaxy and p/n type conductions
15:30	Tu-A3.2 15:55-16:20: K. Uesugi, Homo-epitaxial growth on high temperature annealed AIN template and device applications	Tu-B3.2 15:55-16:20: H. Sun, Deep ultraviolet micro LEDs Tu-B3.3 16:20-16:45: B. Daudin, AIN nanowire LEDs
- 17:30	Tu-A3.3 16:20-16:35: Y. Guo, Improved crystallinity and surface morphology of a-plane AIN grown on r-sapphire by pulsed-flow Mode MOVPE	Tu-B3.4 16:45-17:00: Z. Liu , Principles for 2D Material Assisted Nitrides Epitaxial Growth
27.30	Tu-A3.4 16:35-16:50: C. Margenfeld, Point Defect Engineering for Enhanced Dislocation Annihilation During High-Temperature Annealing of AIN	Tu-B3.5 17:00-17:15: N. Bernhardt, The pursuit of deep-UV defect emitters in 2D hBN
	Templates Tu-A3.5 16:50-17:05: P. Vuong, Investigation of p-type doping in BAIN alloys	Tu-B3.6 17:15-17:30: T. Wei, Graphene-assisted growth of single
	for deep ultraviolet optoelectronics	crystalline GaN on $SiO_2/Si(100)$ for monolithic optoelectronic integration and flexible devices
17:30	Tu-A3.6 17:05-17:30: <u>S. Zhao</u> , AlGaN nanowire LEDs / MBE for UV sources	
17.30	Coffee b	

Tuesday June 6th

Poster Session

2D/Nano

Tu-P1	A. Zaiter, Investigating the role of h-BN on the growth of AIN by MBE	
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- Tu-P2 L. Janicki, Dodecagonal III-nitride microrods a basis for future UV devices
- Tu-P3 I. Pugazhendi, Hybrid CsPbBr3 quantum dots decorated two dimensional MoO3 nanosheets photodetectors with enhanced performance
- Tu-P4 L. Wang, Threading dislocation defects effecting on the optical gain in GaN terahertz quantum cascade laser
- Tu-P5 K. Korona, Kinetics of UV luminescence of LED structures embedded in GaN/AlGaN nanowires
- Tu-P6 A. Kaur, Formation of Two Dimensional Electron Gas (2DEG) in Wedge Shaped Nanostructures of GaN: Validation of the Theoretical Model
- Tu-P7 V. Ottapilakkal, Growth of Thin BN films on C face Epigraphene using MOVPE
- Tu-P8 V. Ottapilakkal, Thermal Stability of Thin hexagonal boron Nitride Grown by MOVPE on Epigraphene
- Tu-P9 R. He, Wafer-Scale Efoliation of AIN Film via hexagonal BN-Assisted van der Waals Epitaxy for Deep-Ultraviolet Light-Emitting Diodes
- Tu-P10 F.Z. Tijent, Hydrogen production and storage using hexagonal boron nitride (h-BN)

AIN/AIGaN

17:45

19:30

- Tu-P11 L. Peters, Sublimation Behavior of AIN in Nitrogen and Argon at Conditions Used for High-Temperature Annealing
- Tu-P12 D. Lee, The effect of thermally treated AIN powder on defect formation of AIN single crystals
- Tu-P13 Z. Kushitashvili, UV Stimulated Technology Receiving Nanoscale III- Nitrides
- Tu-P14 A. Kaminska, Influence of strain on the excitonic bandgap of AIN epitaxial layers grown on Si and sapphire substrates
- Tu-P15 H. Lu, Linearity Improvements of Sub-micrometer AIN/GaN-based Heterostrcuture for Millimeter-wave Applications (To be confirmed)

Oxides

- Tu-P16 T. Hubacek, Surface morphology of diamond grown on III-nitrides layers
- Tu-P17 J. Batysta, Optical properties of diamond layers grown on III-nitrides
- Tu-P18 E. Butanovs, The Effect of a Nucleation Layer on Morphology and Grain Size in MOCVD-Grown β-Ga₂O₃ Thin Films on C-Plane Sapphire
- **Tu-P19 Z. Chi,** Zn Doping Effect on Electrical Transport Properties in β-Ga₂O₃
- Tu-P20 I. Zhelezova, Vacancy defects in Si doped β-(Al,Ga)₂O₃

UV Phot/UV Emit.

- Tu-P21 S. Arora, Electroluminescence Study of Spatially Indirect Interfacial Excitons in n-ZnO/p-GaN Heterostructures
- **Tu-P22** J. Yoshinaga, Epitaxial growth of AlGaN-based deep-ultraviolet light-emitting diodes on a 6-inch sputter-annealed AlN template by using MOCVD system for mass production
- Tu-P23 R. Ren, Lasing threshold reduction of AlGaN based UV-C laser diodes on strain relaxed lower cladding layer (To be confirmed)
- Tu-P24 R. Hernandez, Flexible nanowire UV LEDs
- **Tu-P25 F. Dominec,** Roughness and doping effects on p-diamond/n-nitride heterointerface diodes

	Wednesday June 7 th				
08:30	PLENARY SESSION 2				
- 10:00	We-PS2.1 08:30-09:15: H. Miyake, Sputtering growth of AIN for high quality template and its application for UV LEDs				
10:00	We-PS2.2 09:15-10:00: M. Strassburg, UV-C LEDs – from development to todays and future applications				
10:30	Coffee break				
10.00	A4 UV Phot/UV Char B4 UV emitters				
10:30 _ 12:30	We-A4.1 10:30-10:45: N. Nikitskiy, Anomalous temperature dependence of the emission properties of (Al,Ga)N quantum dots emitting in the UV range We-A4.2 10:45-11:00: A. Perepeliuc, On the origin of giant persistent photoconductivity in hexagonal boron nitride We-A4.3 11:15-11:30: P. Shen, A high-responsivity solar-blind photodetecting paper with sandwiched ZnO nanoarray/hexagonal boron nitride monolayer We-A4.5 11:30-11:45: P. Gao, Atomic Structure and Phonon Transport Behavior of Heterointerfaces in AlN-based Films (To be confirmed) We-A4.7 12:00-12:25: R. Katayama, Deep UV light generation by nitride-based second harmonic generation wavelength conversion devices (To be confirmed) We-B4.7 12:10-12:25: J. Hopfner, Unravelling carrier transport in far-UVC LEDs by temperature dependent electroluminescence with sandwiched ZnO nanoarray/hexagonal boron nitride monolayer We-B4.5 11:25-11:40: Liu, Machine learning design for UVC light-emitting diodes by stacked XGBoost/LightGBM We-B4.6 11:45-12:00: G. Alvarez, Cross-plane thermal conductivity of h-BN grown by pulsed laser deposition We-B4.7 12:00-12:25: R. Katayama, Deep UV light generation by nitride-based second harmonic generation wavelength conversion devices (To be confirmed)				
12:30	measurements				
- 13:30	Lunch / Poster session				
13:30 - 15:30	 We-A5.1 13:30-13:55: X. Li, Ga₂O₃ research from termal-induced growth, photodetectors, to integrated circuits We-A5.2 13:55-14:20: A. Osinsky, Growth of high purity and doped β-Ga₂O₃ films using MOCVD We-A5.3 14:20-14:35: M. Bickermann, Gallium Oxide Bulk Crystals Prepared by the Czochralski Method, (100) Substrates, and Homoepitaxy Results We-A5.4 14:35-14:50: D. Rogers, Zinc Oxide Based Electronics & Photonics: Existing & Emergent Applications We-A5.5 14:50-15:05: N. Bernhardt, Energies and Orientations of the Fundamental Direct Optical Transitions in β-Ga₂O₃ We-A5.6 15:05-15:20: H. Teisseyre, Is SCAM a promising oxide material, or a scam? We-A5.7 15:20-15:35: R-H. Horng, Material Properties of n-type β-Ga₂O₃ heteroepilayers with In-Situ Doping Grown on Sapphire by Metalorganic Chemical Vapor Deposition We-A5.1 13:30-13:55: K. Sakowski, Numerical simulations of AlGaN heterostructures with polarization-doping We-B5.2 13:55-14:20: L. Van Deurzen, Excitonic luminescence in homoepitaxial N-polar AlN grown on bulk substrates We-B5.3 14:20-14:45: A. Khan, Progress and Challenges of Transparent AlGaN-based UVB LEDs We-B5.4 14:45-15:00: N. Declercq, Ultraviolet light used in a historical case study of 1639 We-B5.5 15:00-15:15: E. Nogales, Gallium oxide temperature-dependent refractive index and Cr doped β-Ga₂O₃ nanowires as thermometers 				
15:30 -	Coffee break				
16:00	A6 WBG Phys./Applic. B6 UV emitters				
16:00	We-A6.1 16:00-16:25: R. Kudrawiec, Studies of the electric field distribution in III-N heterostructures and the position of the Fermi level at the van der Waals/III-N interface by contactless electroreflectance in UV We-A6.2 16:25-16:50: W. Miller, Growth kinetics of AlN and AlGaN deposition on AlN(0001): A kinetic Morte Carlo Study.				
_ 17:45	We-A6.3 16:50-17:15: J. Ruschel, Degradation effects - Similarities and differences of UV LEDs with different wavelengths We-A6.4 17:15-17:30: S. Schmult, Highly UV-sensitive AlGaN/GaN Heterostructures grown by MBE We-A6.5 17:30-17:45: A. Srivastava, Electrical Characteristics of p-BN/n-AlGaN Heterostructures We-B6.6 16:40-16:55: R. He, Monolithically integrated AlGaN-based ultraviolet-C photonic chips for solar-blind communications We-B6.4 16:55-17:10: F. Nippert, Carrier dynamics in 230nm-emitting AlGaN quantum wells We-B6.5 17:10-17:25: T. Guillet, Ridge GaN polariton lasers: short lasers for on-chip integration We-B6.6 17:25-17:40: L. Valera, M-plane AlGaN digital alloy for microwire UV-B LEDs				
19:00 -	Banquet				
23:00	244400				

Thursday June 8 th				
08:30	PLENARY SESSION 3			
- 10:00	Th-PS3.1 08:30-09:15: A. Allerman, AlGaN Alloys for Next Generation Power Electronics			
10:00	Th-PS3.2 09:15-10:00: M. Kneissl, Perspectives of AlGaN-based DUV LEDs and their applications			
- 10:30	Coffee break			
	A7 2D/Nano B7 UV emitters			
10:30 - 12:30	Th-A7.1 10:30-10:55: S. Sundaram, Layered Boron Nitride for deep UV optoelectronics Th-A7.2 10:55-11:10: E. Vuillermet, Surface nano-structuration of 4H-SiC by controlled high-temperature annealing Th-A7.3 11:10-11:25: S. Novikov, High-temperature molecular beam epitaxy of hexagonal boron nitride and hBN-graphene-hBN lateral heterostructures Th-A7.4 11:25-11:40: N. Gao, Enhancing deep-UV sub-250 nm light emission based on truncated pyramid AlN/GaN nanostructure with fine-tuned multiple facets Th-A7.5 11:40-11:55: R. Vermeersch, Shallow donors and DX states in AlN Nanowires Th-B7.6 11:55-12:10: S. Huang, Deep-UV distributed Bragg reflectors with 93% reflectivity for low threshold lasers Th-B7.2 10:55-11:10: S. Huang, Deep-UV distributed Bragg reflectors with 93% reflectivity for low threshold lasers Th-B7.3 11:10-11:25: G. Cardinali, Single-mode operation of optically pumped UVB VCSELs enabled by circular surface structures Th-B7.4 11:25-11:40: N. Akaminska, Emission properties of GaN/AIN and AlGaN/AIN polar multi-quantum wells – experimental and ab initio study Th-B7.5 11:40-11:55: A. Zaiter, Growth of (Al, Ga)N Quantum Dots on h-BN and Exfoliation Processes towards the Fabrication of Flexible Efficient UV-C LEDs Th-B7.6 11:55-12:10: S. Huang, Deep-UV distributed Bragg reflectors with 93% reflectivity for low threshold lasers Th-B7.5 11:10-11:25: G. Cardinali, Single-mode operation of optically pumped UVB VCSELs enabled by circular surface structures of GaN/AIN and AlGaN/AIN polar multi-quantum wells – experimental and ab initio study Th-B7.5 11:40-11:55: A. Zaiter, Growth of (Al, Ga)N Quantum Dots on h-BN and Exfliction Processes towards the Fabrication of Flexible Efficient UV-C LEDs			
	Th-A7.6 11:55-12:10: L. Valera, Wire-based UV-μLED using GaN and AIN microwires as template Th-A7.7 12:10-12:25: Z. Liu, Transferable Ga ₂ O ₃ Membrane Exfoliated from Muscovite Mica Platform for Vertical Electronics Th-B7.6 11:55-12:10: K. Zhang, AlGaN multiple quantum wells regrown on N-polar AIN/4H-SiC template fabricated by sputtering and high temperature annealing Th-B7.7 12:10-12:25: N. Maeda, Current-induced p-type activation of Mg-doped and highly Al compositional (x > 0.8) AlGaN observed during initial energization of 220 nm band far-UVC LEDs (To be confirmed)			
12:30	Lunch / Poster session			
13:30	Lunch / Poster Session			
	A8 Oxides B8 AlGaN/AlN			
13:30 - 15:30	 Th-A8.1 13:30-13:55: M. Liao, Diamond-based photodetector Th-A8.2 13:55-14:20: K. Kaneko, Germanium dioxide (GeO2) as a new power device material Th-A8.3 14:20-14:35: C-Y Huang. β-Ga₂O₃ MOSFETs electrical characteristic study of various etching depths grown on sapphire substrate by MOCVD Th-A8.4 14:35-14:50: B. Mendez, Luminescence of doped Ga₂O₃ nanowires Th-A8.5 14:50-15:05: M. Narayanan, Ga₂O₃: Examining electrical conduction and the role of oxygen vacancies Th-A8.6 15:05-15:20: D. Maestre, Elongated micro- and nanostructures formed by Ni and Mn oxides synthesized by a vapor solid method Th-B8.6 14:55-15:20: X. Wang, High performance AlGaN-based UVC- and UVB-LEDs on nano patterned sapphire substrate (To be confirmed) 			
15:30 -	Coffee break			
16:00 16:00 - 17:00	Th-AB9.1 16:00-16:15: J. Canas, AlGaN/AIN quantum dots: Growth optimization for electron-beam pumped deep-UV emitters Th-AB9.2 16:15-16:30: C. Manz, Improvements in MOCVD-growth of AlGaN-based solar-blind photodetectors Th-AB9.3 16:30-16:45: I. Prozheev, Electrical compensation in Al rich Si-doped 90% AlGaN determined by positron annihilation and X-ray absorption spectroscopy Th-AB9.4 16:45-17:00: J. Wang, Reduction of threading dislocations in heteroepitaxial AIN films by extrinsic supersaturated vacancies engineering (To be confirmed)			
17:00 -	Late News			
17:45				
17:45 –	Closing			
18:15				